

## PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2002-094187

(43)Date of publication of application : 29.03.2002

(51)Int.Cl.

H01S 5/323

H01S 5/183

(21)Application number : 2000-286870

(71)Applicant : HITACHI LTD

(22)Date of filing : 18.09.2000

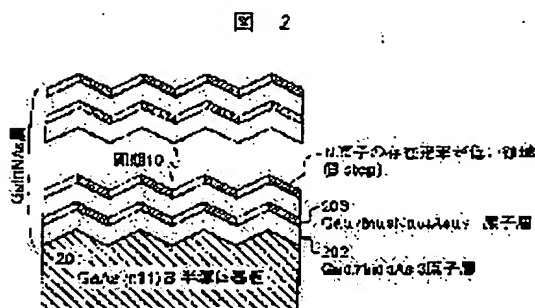
(72)Inventor : KITATANI TAKESHI  
KONDO MASAHIKO  
TANAKA TOSHIKI

(54) SEMICONDUCTOR LASER AND OPTICAL COMMUNICATION SYSTEM USING IT

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a semiconductor laser having a nitrogen-containing III-IV compound semiconductor layer in which PL peak energy does not shift largely even when the layer is subjected to annealing in manufacturing the laser.

SOLUTION: The semiconductor layer is provided with an active layer which generates light, a clad layer which confines the generated light, and a resonator structure which obtains laser light from the generated light. The active layer has the nitrogen-containing III-V compound semiconductor layer in which nitrogen atoms constituting the layer are arranged with fixed periodicity.



## LEGAL STATUS

[Date of request for examination]

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[0012]

[Embodiments of the Invention]

An example of a specific process of periodically disposing N atom will be described. Herein, in order to describe the process of periodically disposing N atom, other processes are omitted. In the example shown in Fig. 1, a GaAs (100) substrate 101 is used as a growth substrate, and,  $\text{Ga}_{0.7}\text{In}_{0.3}\text{As}$  3 atomic layers 102 and  $\text{Ga}_{0.7}\text{In}_{0.3}\text{N}_{0.04}\text{As}_{0.96}$  1 atomic layer 103 are alternately disposed. By thus alternately stacking a plurality of different semiconductor layers with a thickness of several atomic layers, it becomes possible to periodically dispose layers in which N atom exists and layers in which N atom does not exist in a growth direction. When the number of periods is set to 10, a total film thickness is approximately 10nm. In this case, the film has a pseudo-composition equivalent to  $\text{Ga}_{0.7}\text{In}_{0.3}\text{N}_{0.01}\text{As}_{0.99}$ . In a quantum well structure in which the film is used as a well layer and GaAs is used as a barrier layer, a wavelength shift amount in annealing has been reduced from conventional 60nm to 30nm, and an emission of light in a 1.3 $\mu\text{m}$  band compatible with optic fiber communications has been achieved.

[0013]

Another example is shown in Fig. 2. Herein, a GaAs (n11) B substrate 201 is used as a substrate (n: positive integer). It has been reported that N atom hardly sticks to thus inclined B step position of the substrate, in the 46<sup>th</sup> Oyo Butsurigaku Kankeiren Koenkai Koen Yokoshu p. 48, 29p-T-6. Therefore, as in the above-described example shown in

Fig. 1, when  $\text{Ga}_{0.7}\text{In}_{0.3}\text{As}$  3 atomic layers 202 and a  $\text{Ga}_{0.7}\text{In}_{0.3}\text{N}_{0.04}\text{As}_{0.96}$  1 atomic layer 203 are alternately stacked in 10 periods, a region in which N atom exists and a region in which N atom does not exist are formed both in a growth direction and a direction perpendicular to the growth direction as shown in the drawing, and two-dimensional periodicity may be introduced to distribution thereof. In the structure of this invention, the wavelength shift amount in annealing has been reduced from conventional 60nm to 20nm with a GaAs (311) B substrate, and an effect larger than that in the example shown in Fig. 1 is obtained. To obtain larger effect, it is desirable to set n (the positive integer) of the substrate used to be as small as possible. When n is set to not larger than 10, sufficient effect will be obtained.

Fig. 1

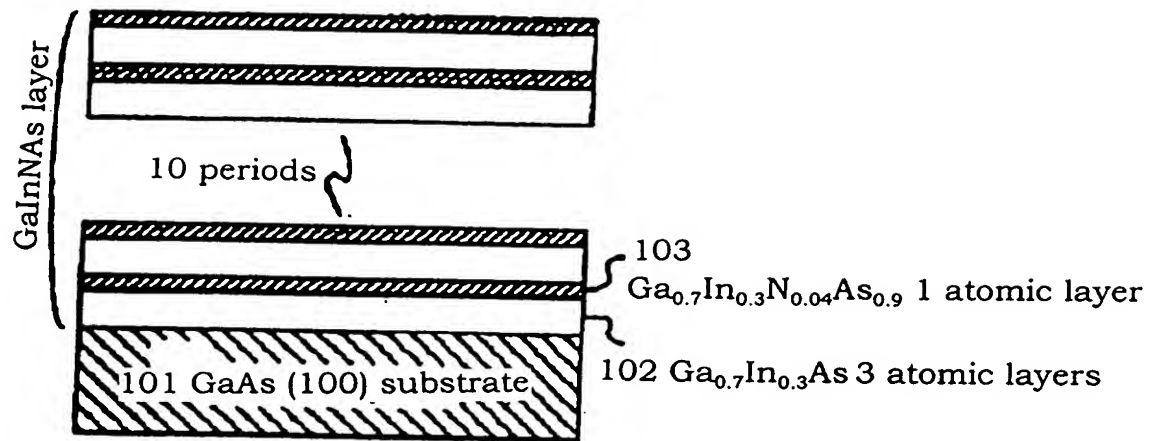


Fig. 2

